# No-D NMR for Delta Version 5

No-D NMR is a method to measure NMR spectra of organic compounds without deuterated solvents. JEOL's latest NMR software, Delta Ver.5, includes automation sequences for No-D NMR, as standard. The sequences can be used more easily than the previous ones, more solvents can be selected, and so more promising.



• Time for preparing samples can greatly be reduced, because reaction solutions can be used as they are.

• Unstable samples can be measured, because the process of dissolving samples is omitted.

• The cost for deuterated solvents can be saved.

## < Simplified setting parameters and selecting solvents >

Methodパラメータ

	wet_atn	58[dB]	
	wet_solvent	Chloroform 🛊	
►	peaks	1	
	scans	8	
	force_tune		
►	rgain	20	
	autogain	Ø	
			T

When an automation sequence is selected, only the parameters often changed are displayed as method parameters, providing efficient setting.

A measuremtent can immediately be started, when

wet\_solvent: name of solvent
peaks: number of solvent peaks are set. As standard, 22 normal solvents can be selected, and more solvents can be added on request.

\* The othe parameters are in the subdirectory.

## < Automatic detection of solvent peaks and adjustment of reference >



No-D automation sequence starts with a 1-scan <sup>1</sup>H measurement to search a solvent signal (scout scan). Then, WET measurement is performed to suppress the solvent signal and also set reference using the signal. Hence, users can save the step of setting reference.

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### < No-D NMR when a solvent gives more than one peak >

WET sequence has an advantage of suppressing more than one solvent peak at once, and so No-D NMR is applicable to such solvents. In the example of methanol, two peaks are suppressed by setting peaks to be 2.



Butyl benzoate / Water,Acetone

## < List of selectable solvents > =

acetic acid, acetone, acetonitrile, benzene, chloroform, cyclohexane, DMF, DMSO, ethanol, hexafluoro-2-propanol, isopropanol, methanol, methylene chloride, nitromethane, *o*-dichlorobenzene, *p*-dioxane, pyridine, tetrachloroethane, tetrahydrofuran, toluene, trifluoroacetic acid, trifluoroethanol \* More solvents can be added on request. However, note that adjacent peaks may accidentally suppressed if many solvents are specified.

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